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United States Design Patent

Yee

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(54) **MEMORIAL MASK MEMENTO**

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(**) Term: **15 Years**

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(51) **LOC (15) Cl.** **11-02**

(52) **U.S. Cl.**
USPC **D11/157**; D24/110.1

(58) **Field of Classification Search**
USPC D11/204, 48, 81, 99, 131, 133, 157, 184;
D99/17, 21; D24/110.1
CPC A41D 13/1115
See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a memorial mask memento as shown and described.

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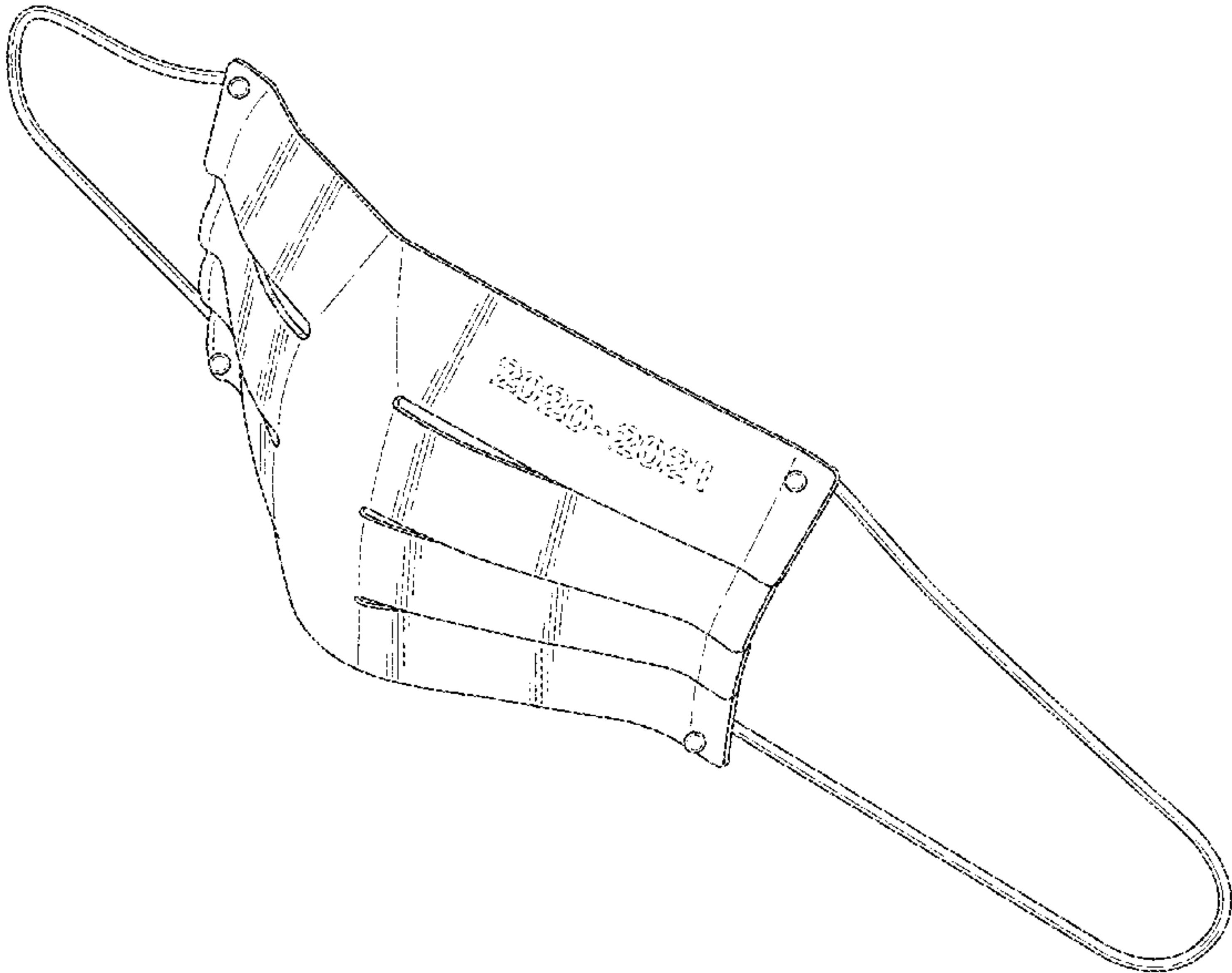
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DESCRIPTION

FIG. 1 is a perspective view showing the front, top, and right side of the memorial mask memento;
FIG. 2 is a front, bottom, and right side perspective view thereof;
FIG. 3 is a rear, top, and left side perspective view thereof;
FIG. 4 is a front view thereof;
FIG. 5 is a back view thereof;
FIG. 6 is a left side view thereof;
FIG. 7 is a right side view thereof; and,
FIG. 8 is a top view thereof.
The broken lines illustrate environment and form no part of the claimed design.

1 Claim, 8 Drawing Sheets



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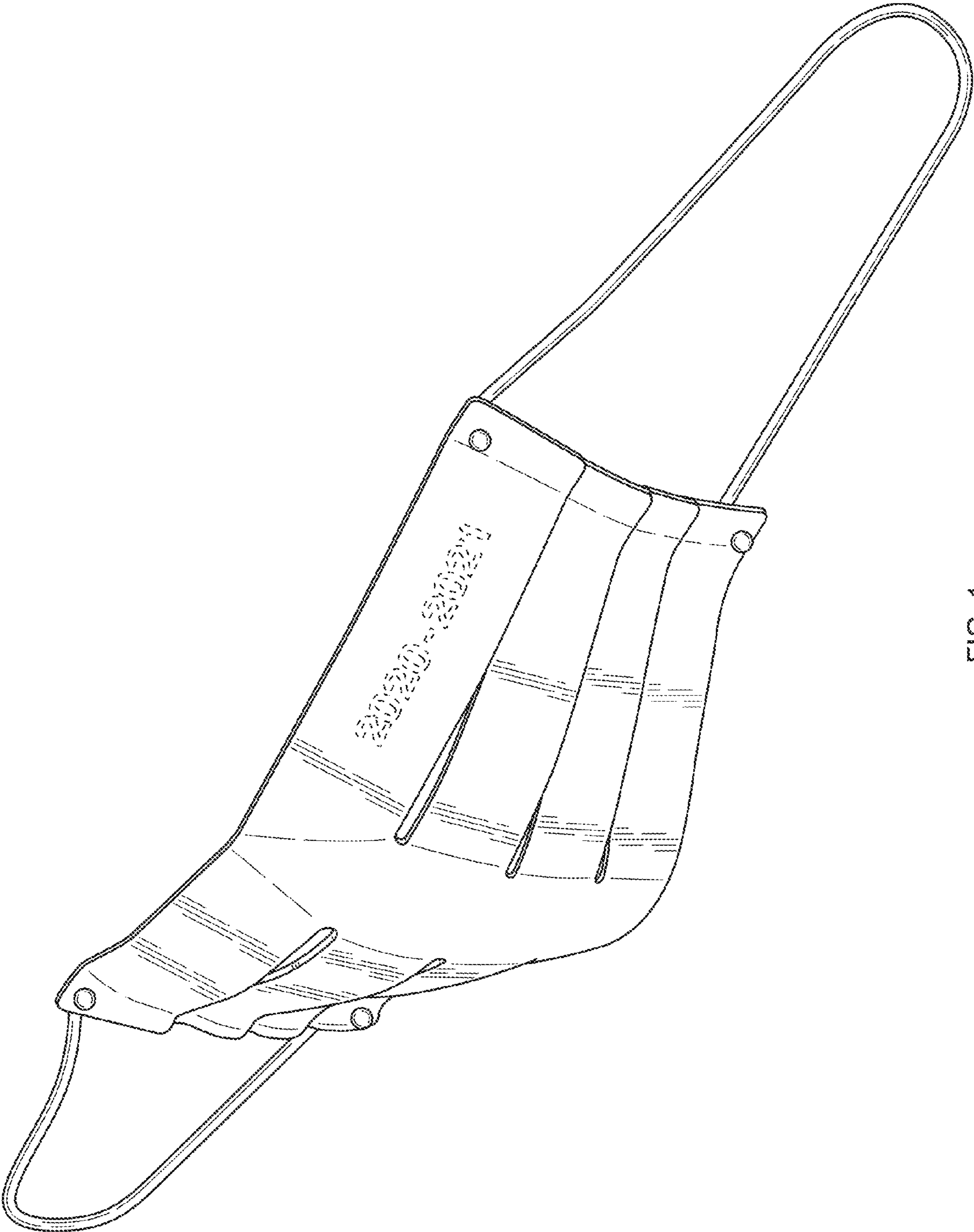


FIG. 1

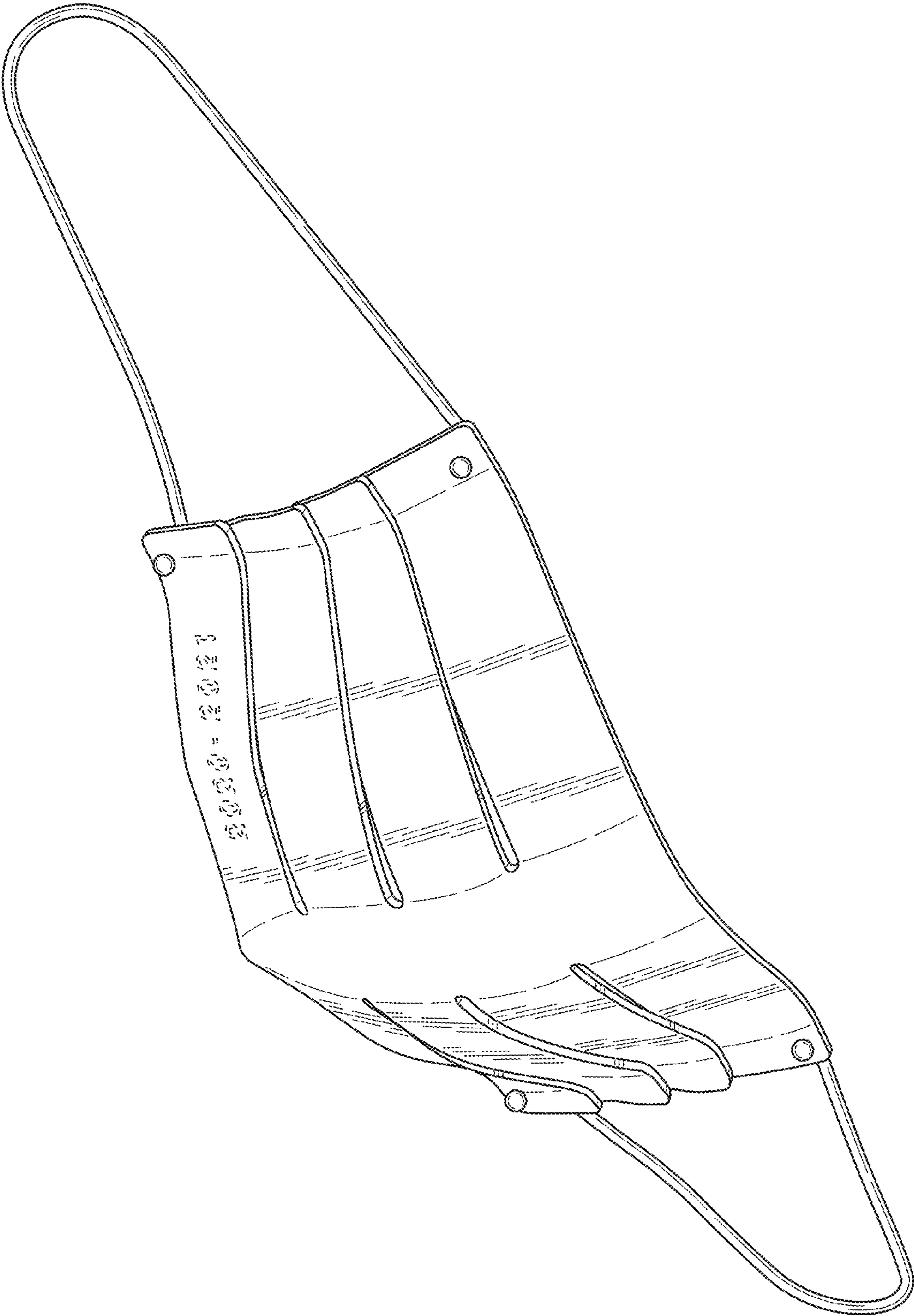


FIG. 2

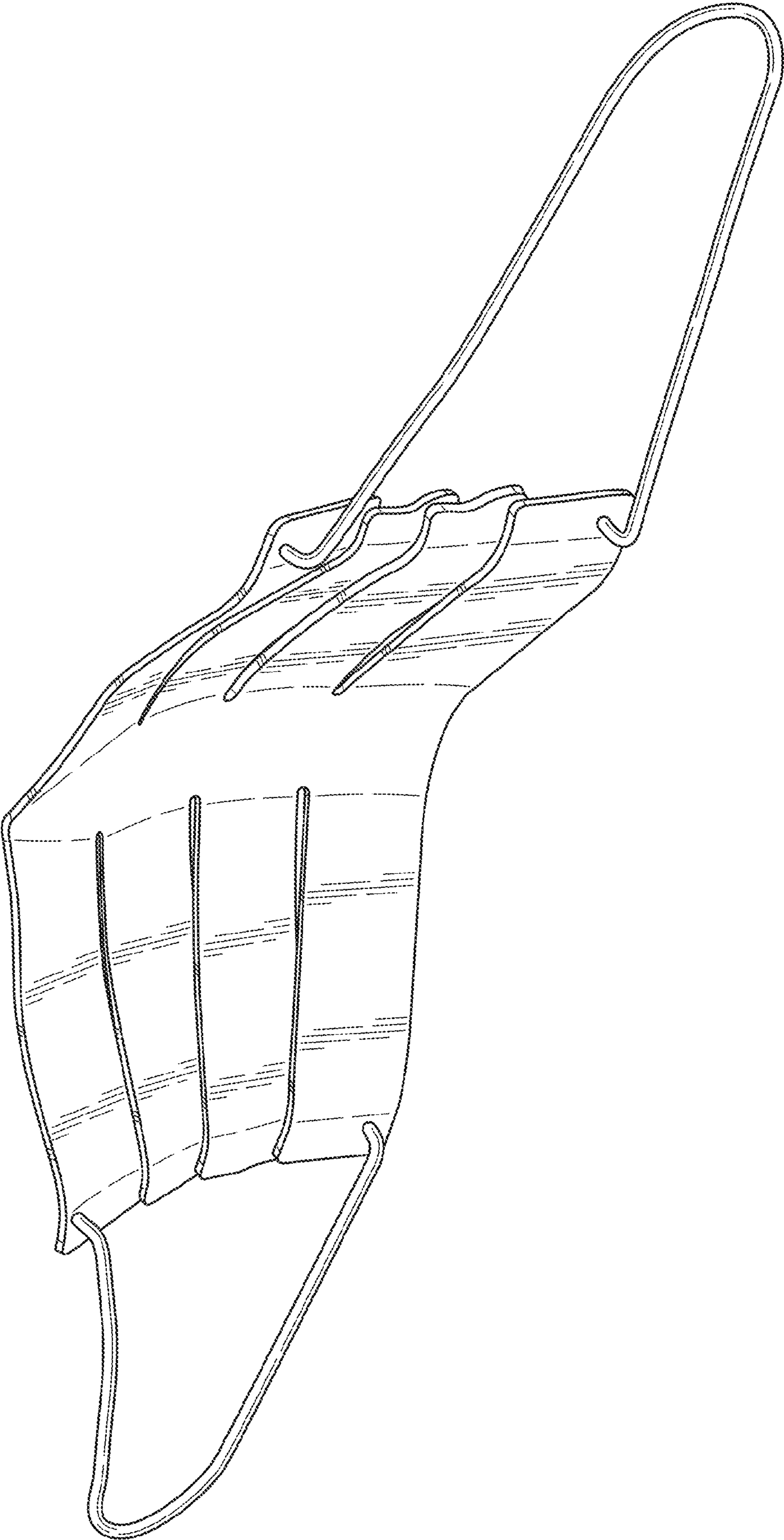


FIG. 3

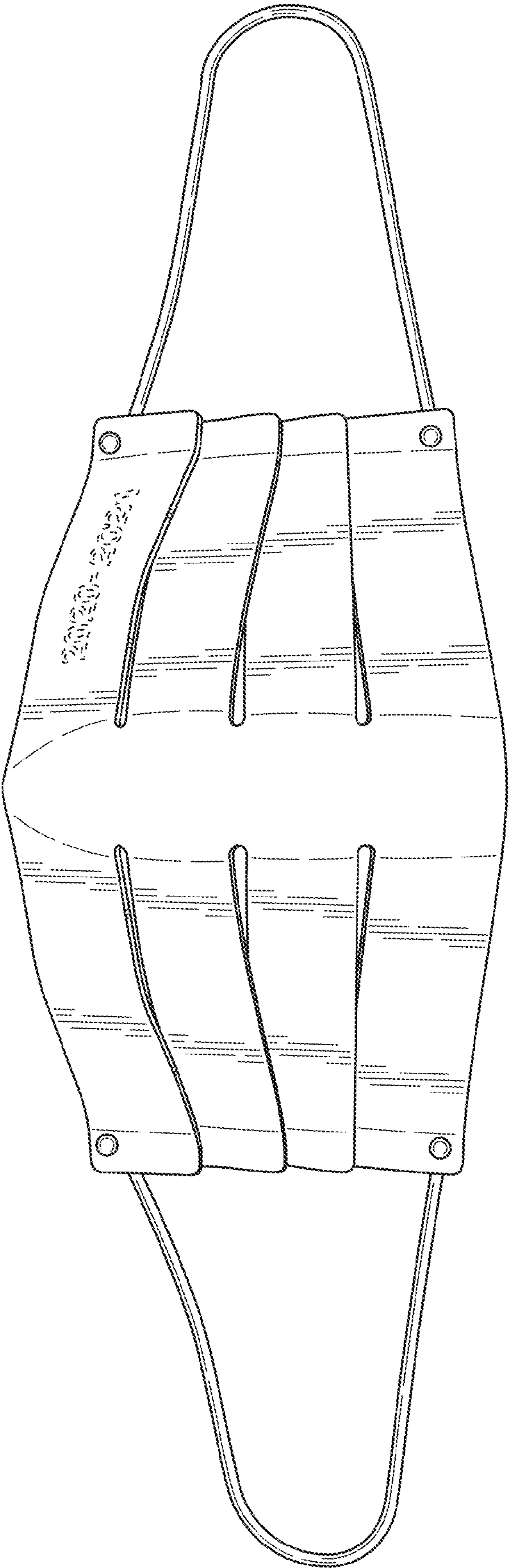


FIG. 4

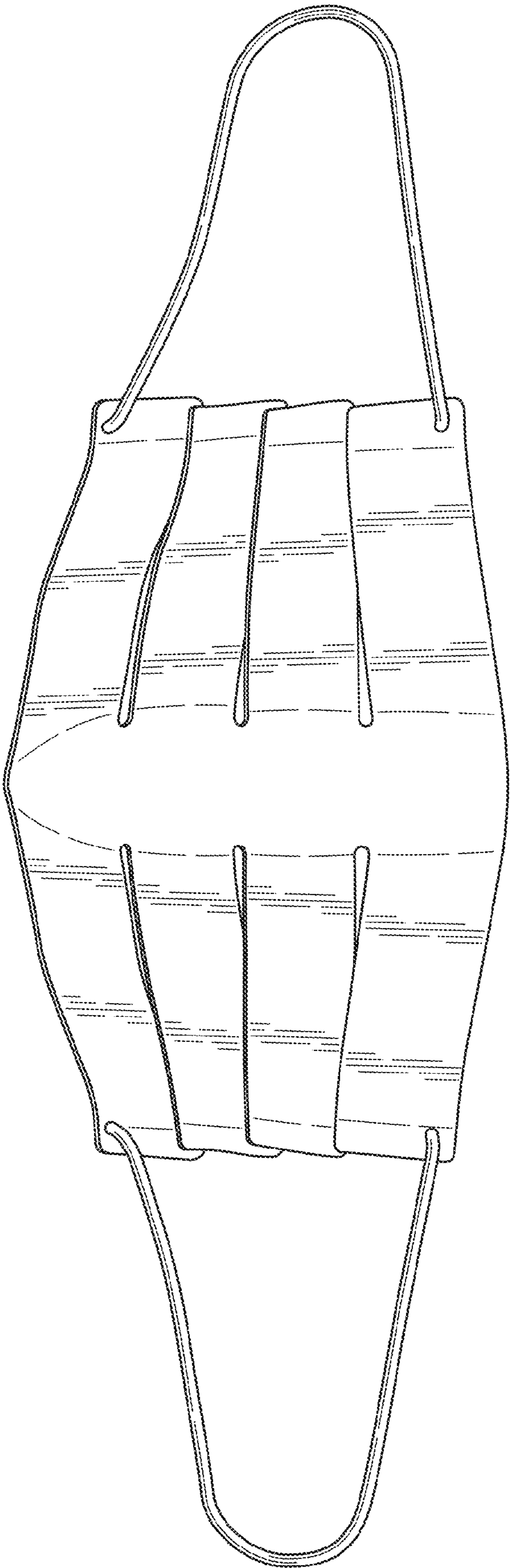


FIG. 5

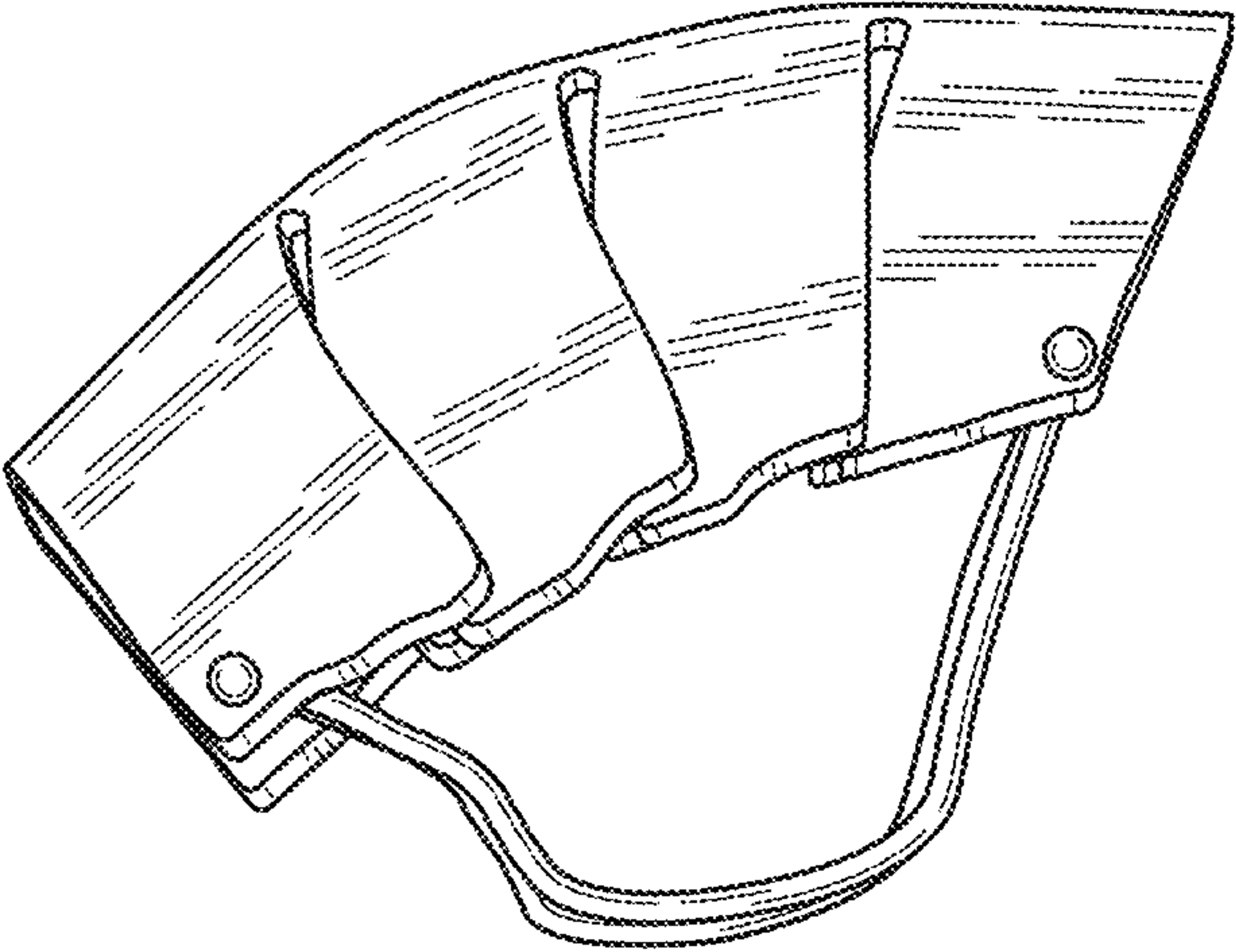


FIG. 6

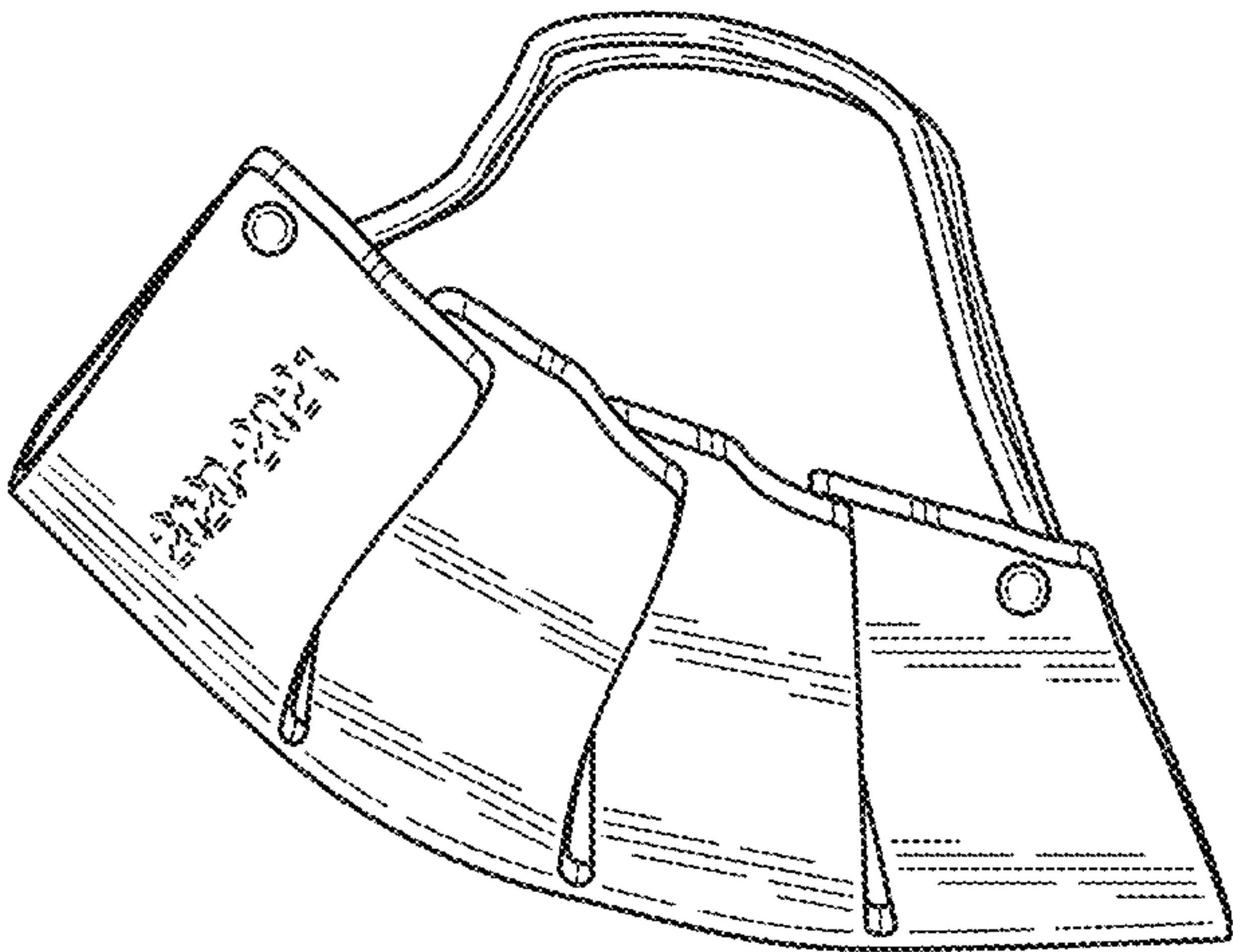


FIG. 7

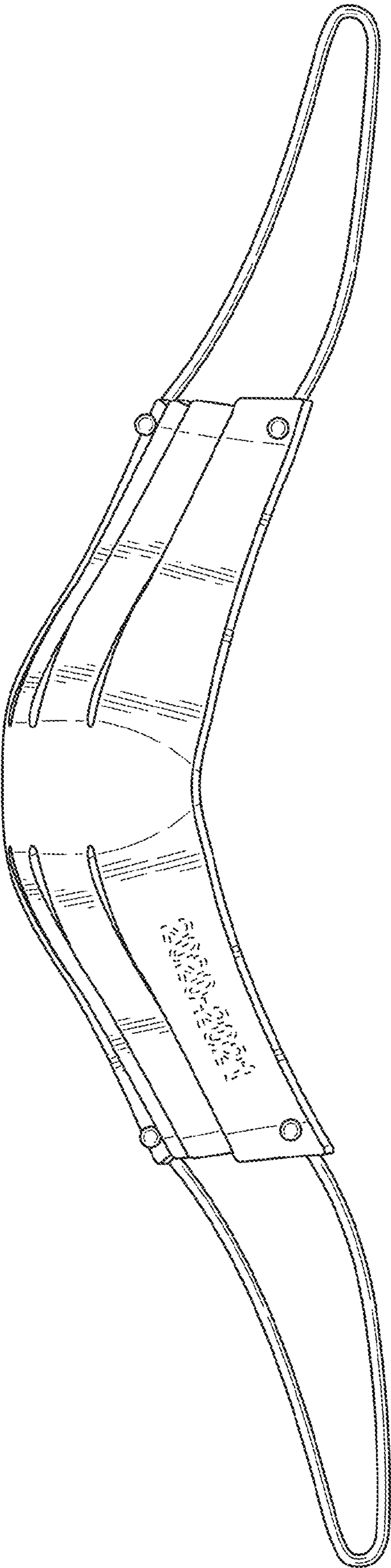


FIG. 8